



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

APPLICANT: Chang Chul Ha et al.  
APPLICATION NO.: 10/080,057  
FILING DATE: February 20, 2002  
TITLE: Patterned Seed Layer Suitable for Electron-Emitting Device, and  
Associated Fabrication Method  
EXAMINER: Elizabeth Marie Keaney  
GROUP ART UNIT: 2882  
ATTY. DKT. NO.: 23976-08191

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Dated: April 28, 2005

By: 

**Robert A. Hulse, Reg. No.: 48,473**

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SIR:

Pursuant to the provisions of 37 CFR §§ 1.56 and 1.97-98, enclosed herewith is modified form PTO/SB/08A listing references for consideration by the Examiner.

The filing of this Information Disclosure Statement shall not be construed as a representation regarding the completeness of the list of references, or that inclusion of a reference in this list is an admission that it is prior art or is pertinent to this application, or that a search has been made, or as an admission that the information listed is, or may be considered to be, material to patentability, or that no other material information exists, and shall not be construed as an admission against interest in any manner.

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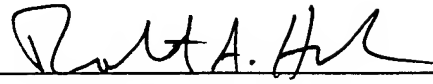
- ☒ within three months of the filing date of the application, or date of entry into the national stage of an international application, or before the mailing date of a first office action on the merits, whichever event last occurred;
- ☒ Enclosed is a copy of each listed reference that may be material to the examination of this application, and for which there may be a duty to disclose.

Consideration of the listed references and favorable action are solicited.

**PATENT**

Respectfully submitted,  
CHANG CHUL HA ET AL.

Dated: Apr 28, 2005

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<b>Substitute for form 1449A/PTO</b>  <b>INFORMATION DISCLOSURE STATEMENT BY APPLICANT</b>				<b>Complete if Known</b>	
				Application No.	10/080,057
				Filing Date	February 20, 2002
				First Named Inventor	Chang Chul Ha
				Art Unit	2882
				Examiner Name	Elizabeth Marie Keaney
Sheet	1	of	1	Attorney Docket Number	23976-08191

U.S. PATENT DOCUMENTS				
Examiner Initials*	Cite No. <sup>1</sup>	Document No. Number – Kind Code <sup>2</sup> (if known)	Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document
	A1	US-5,496,200	03-05-1996	Yang et al.
	A2	US-5,789,856	08-04-1998	Itoh et al.
	A3	US-5,828,163	10-27-1998	Jones et al.
	A4	US-5,847,407	12-08-1998	Lucero et al.
	A5	US-5,872,422	02-16-1999	Xu et al.
	A6	US-6,204,597 B1	03-20-2001	Xie et al.

FOREIGN PATENT DOCUMENTS					
Examiner Initials*	Cite No. <sup>1</sup>	Foreign Patent Document Country Code <sup>3</sup> – Number <sup>4</sup> Kind Code <sup>5</sup> (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	T <sup>6</sup>

OTHER REFERENCES – NON-PATENT LITERATURE DOCUMENTS				
Examiner Initials*	Cite No. <sup>1</sup>	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published	T <sup>6</sup>	

Examiner Signature		Date Considered	
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\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609.

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